

General Information

Location of Seminar

Legend Hotel, Saigon

Dates

March 19 and 20, 2007

Language

All sessions are held in English.

Application and Registration Fees

Applications, and payment of the registration fees, **11,500 yen** per person, will be accepted **online only**, on a first-come-first-serve basis. Links to the online registration form and additional information can be found on the JPAA website:

www.jpaa.or.jp/english/index.html

The registration fee includes all seminar materials, coffee breaks, lunches, and the Welcoming Reception. All other expenses, including hotel accommodations, are the responsibility of the attendee.

Accommodation

Participants are responsible for their own hotel accommodations. A block of rooms at the Legend Hotel, Saigon have been reserved at a discounted rate of US\$130 per night for a single or twin room; participants wishing to stay at the Legend Hotel should contact the hotel directly to make reservations, and should request this rate.

Legend Hotel, Saigon
2A-4A Ton Duc Thang Street
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Cancellation and Liability

Attendees are encouraged to purchase travel insurance as the organizers will assume no liability and the registration fee is not refundable.

Visas

All attendees are responsible for obtaining whatever visas they may require to travel to Vietnam. While the organizers will make a reasonable effort to provide documentation as requested by governmental authorities, participants should make any such requests as soon as possible.

Smoking Policy

For the comfort and health of all attendees, no smoking will be allowed in the classrooms; smoking will only be permitted in designated smoking areas.

Speakers

ASAI Kenji, Nakamura & Partners FUJII Shunsuke, Meisei International Patent Firm HASHIMOTO Yoichi, OCEANS INTELLECTUAL PROPERTY OFFICE KOSHIKAWA Takao, KOSHIKAWA & Co. MATSUI Takao, OKABE International Patent Office MORITA Kenichi, MORITA PATENT OFFICE NAKA Koichi, NAKA International Patent Office NAKAJIMA Takanori, AOYAMA & PARTNERS NISIO Tutomu, Hiroe and Associates NODA Masaichi, Soei Patent & Law Firm SAITO Junko, Ishida & Associates SAKUMA Yoko, ESAKI & ASSOCIATES SUGIMURA Junko, SUGIMURA, TAMURA & PARTNERS TAKAHARA Chizuko, ASAMURA PATENT OFFICE TANAKA Hideki, Arai, Tanaka & Associates TASAKA Kazuaki, Yamasaki & Partners TOYOSAKI Reiko, TOYOSAKI & ASSOCIATES

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2007 JPAA IP Practitioners Seminar



March 19-20, 2007

Ho Chi Minh City

Vietnam

Organized and Sponsored by

Japan Patent Attorneys Association

Vietnam Organizer

Kelvin Chia Partnership

Supported by

National Office of Intellectual Property of Viet Nam (NOIP)

Vietnam Intellectual Property Association (VIPA)

The Intellectual Property Associations of Ho Chi Minh City (IPA)

Program

Designed especially to fulfill the practical needs of intellectual property practitioners and creators, over the course of two days this seminar will provide attendees with a working overview of the Japanese system and environment. Each session will provide specific tools and information that applicants, small and large, and their agents can use to smooth prosecution, increase the value of their intellectual property, and reduce overall costs.

Monday's sessions will be designed for general interest, while on Tuesday, participants will be able to select between two tracks, *Patents and Designs* or *Trademarks and Unfair Competition Prevention Law*. To increase the applicability to real world problems, a number of Tuesday's sessions will return to the real example of how one small Japanese company effectively used IP rights to protect the "stretching board" it developed.

Coffee breaks, meals, and the complimentary Welcoming Reception will provide participants with opportunities to informally network with session presenters and fellow participants.

Monday, March 19

All Participants

08:30-09:00 Welcoming Remarks

09:00-09:45 Session M-1
Japan's Intellectual Property Policy Today

Mr. TASAKA Kazuaki

In 2002 the Government of Japan began a program of actively supporting the creation and use of intellectual property rights. The session will outline some of the ongoing efforts, including the activities of the Japan Patent Attorneys Association (JPAA), and explain how overseas applicants can take advantage of this work.

09:45-10:30 Session M-2
Recent Developments in Japanese Law

Mr. NODA Masaichi & Mr. NAKA Koichi

Many revisions to Japanese laws related to intellectual property were passed in 2006, with some changes only taking effect this year. The session will highlight the major changes, especially those that will affect overseas applicants.

10:30-11:00 Coffee Break

11:00-11:45 Session M-3
A Checklist for Foreign Patent Applicants

Mr. HASHIMOTO Yoichi

The JPO requires certain specific information and documents from applicants outside of Japan. This session will outline these requirements so that applicants can save time and money at the time of filing a new application.

11:45-12:30 Session M-4
Searching Japanese Patent and Trademark Databases

Mr. KOSHIKAWA Takao & Ms. SAITO Junko

Pre-filing searches can save prosecution costs and help in the drafting of new applications. This session will explain how to use free resources, such as the IPDL database, to search for Japanese patent and trademark publications.

12:30-14:00 Lunch

14:00-14:45 Session M-5
Invalidation Trials and Appealing to the IP High Court

Mr. MATSUI Takao

Defendants in patent infringement suits will commonly look towards invalidating the issued patent. In Japan, any party may request invalidation of any issued patent at any time. This session will outline the JPO Invalidation Trial system and appeals to the IP High Court.

14:45-15:30 Session M-6
Infringement Litigation and Alternative Dispute Resolution

Ms. SUGIMURA Junko

The presenter, drawing on her experience as a Judicial Technical official for Tokyo District Court, will outline recent infringement litigation systems and procedures in Japan, explain how to reduce litigation costs, and introduce alternatives to costly litigation.

15:30-16:00 Coffee Break

16:00-17:30 Sessions M-7 and M-8
Recent Case Law

Mr. ASAII Kenji

This session will use recently-decided cases involving patent law to highlight key points of concern to applicants, such as how a court is likely to determine infringement, literally or through the Doctrine of Equivalents.

18:00 Complimentary Welcoming Reception

Tuesday, March 20

Patents and Designs Track

09:00-10:30 Sessions P-1 and P-2
Patent Application Procedures

Mr. NISIO Tutomu

An overview of Japanese patent application procedures in Japan will be presented, with comparison to the laws of Vietnam. The history of a real Japanese company with only 10 employees that used intellectual property rights to establish a profitable monopoly on "stretching boards" will provide an example of effective use of patent rights.

10:30-11:00 Coffee Break

11:00-12:30 Sessions P-3 and P-4
Drafting Practical Patent Claims

Mr. MORITA Kenichi

The scope of protection of any issued patent is determined by the claims. This session will provide a few techniques for strengthening the value of claims, and avoiding common pitfalls.

12:30-14:00 Lunch

14:00-15:30 Sessions P-5 and P-6
Effectively Responding to Rejections

Mr. FUJII Shunsuke

Very few patent applications are allowed without the issuance of at least one Notice of Rejection. This session will provide tools for effectively responding to JPO rejections, at low cost and without compromising on the scope of the resulting patent.

15:30-16:00 Coffee Break

16:00-17:30 Sessions P-7 and P-8
Design Application Procedures

Mr. NAKAJIMA Takanori

This session will provide a simple introduction of Japanese design law, and outline major revisions made in 2006. With reference to Vietnamese design law, the session will deal with topics such as subject matter protectable by Japanese design law, registration requirements, application and examination procedures, and effective use of design rights.

17:30-17:40 Closing Remarks

Trademarks and Unfair Competition Prevention Law Track

09:00-09:45 Session T-1
Practical Tips for Quick, Low-cost Registration

Ms. TOYOSAKI Reiko

This session will outline strategies for applying for trademark protection in Japan and provide tips, such as how to specify designations to conform with Japanese practice, that will assist in obtaining registration smoothly, without costly rejections.

09:45-10:30 Session T-2
Standards for Determining Similarity of Trademarks in Japan

Ms. SAKUMA Yoko

This session will summarize Japanese examination guidelines and highlight recent decisions to illuminate current trends in similarity judgment, including judgments based on the Unfair Competition Prevention Law.

10:30-11:00 Coffee Break

11:00-11:45 Session T-3
An Overview of Distinctiveness

Ms. SAKUMA Yoko

This session will present examples of trademarks which acquired distinctiveness through use, and overview the Japanese practice concerning three-dimensional marks and judgment of their distinctiveness.

11:45-12:30 Session T-4
Recent Significant Judicial Precedents

Mr. TANAKA Hideki

The session will overview some important precedent-setting judicial decisions under the Trademark Law or the Unfair Competition Prevention Law.

12:30-14:00 Lunch

14:00-15:00 Session T-5
Practical Effects of the Madrid Protocol: Tips for the Practitioner

Ms. TAKAHARA Chizuko

The Madrid Protocol became effective in Japan on March 14, 2000. This session will present tips for effectively using the Madrid Protocol to obtain protection in Japan, while avoiding mistakes commonly made by overseas applicants.

15:00-15:30 Coffee Break

15:30-16:30 Session T-6
Protecting Product Shapes

Ms. SAITO Junko

Many companies expand a great deal of energy to design and sell products with novel shapes. This session will explain how to use the Design Law, the Trademark Law, and the Unfair Competition Prevention Law to protect product shapes in Japan.

16:30-17:30 Session T-7
Using Opposition and Invalidation Procedures to Your Benefit

Mr. HASHIMOTO Yoichi

This session will explain how to use Japan's Opposition and Invalidation Procedures to remove barriers to doing business in Japan, with a special emphasis on tools useful for overseas practitioners.

17:30-17:40 Closing Remarks